

	Application No.	Applicant(s)
	Application 110.	
Notice of Allowability	10/612,944	LEE, SUNG-KWON
Notice of Anowabinty	Examiner	Art Unit
	Julio J. Maldonado	2823
Th MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIOF the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this ap or other appropriate communication IGHTS. This application is subject	oplication. If not included in will be mailed in due course. <b>THIS</b>
1. This communication is responsive to		
2. 🔀 The allowed claim(s) is/are <u>1-8</u> .		
3. A The drawings filed on <u>07 July 2003</u> are accepted by the Examiner.		
<ul> <li>4.  Acknowledgment is made of a claim for foreign priority ur <ul> <li>a)  All b)  Some* c)  None of the:</li> <li>1.  Certified copies of the priority documents have</li> <li>2.  Certified copies of the priority documents have</li> <li>3.  Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)).</li> <li>* Certified copies not received:</li> </ul> </li> <li>Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.</li> </ul>	been received. been received in Application No cuments have been received in this of this communication to file a reply	national stage application from th
<ol> <li>A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give</li> </ol>	itted. Note the attached EXAMINEF es reason(s) why the oath or declar	R'S AMENDMENT or NOTICE OF ation is deficient.
6. CORRECTED DRAWINGS ( as "replacement sheets") mus	t be submitted.	
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached		
1)  hereto or 2)  to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Repiacement sheet(s) should be labeled as such in t		
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT		
Attachment(s)		
1. ☑ Notice of References Cited (PTO-892)	5. Notice of Informal	Patent Application (PTO-152)
2.   Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☑ Interview Summary	
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date		Paper No./Mail Date <u>20040507</u> .  7. ⊠ Examiner's Amendment/Comment
4. Examiner's Comment Regarding Requirement for Deposit	8. X Examiner's Statem	ent of Reasons for Allowance
of Biological Material	9.  Other	
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## **EXAMINER'S AMENDMENT**

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Yoon S. Ham (Reg. No. 45,307) on 05/06/2004.

The application has been amended as follows: in claim 3, lines 1 and 2, where applicants recite "... wherein the conductive pattern is a bit line pattern..." replace with – wherein each of the conductive patterns is a bit line pattern--.

## Allowable Subject Matter

- 2. Claims 1-8 are allowed.
- 3. The following is an examiner's statement of reasons for allowance:

The prior art of record, Dennison to U.S. 5,362,666 teach in Figs.1-14 and related text a method of forming a semiconductor device having a first region and a second region comprising the steps of forming a plurality of conductive patterns (24, 26) on a substrate (12) in the first region and the second region, wherein each of the conductive patterns (24, 26) includes sequentially stacked layers of a conductive layer (24, 26) and a hard mask (28); removing the hard mask (28) in the second region to expose the conductive layer (24, 26); depositing an insulation layer (32, 58) on the entire resulting substrate (12) structure in the first region and the second region; selectively etching the insulation layer (32, 58) in the second region to form an opening

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(38) exposing the conductive layer (24, 26); and forming a conductive wire electrically connected to the conductive barrier layer through the opening (column 9, line 7 – column 12, line 51).

Dennison fails to teach forming a diffusion barrier layer on the exposed conductive layer; etching the insulation layer in the second region to form an opening exposing the diffusion barrier layer; and forming a conductive wire electrically connected to the diffusion barrier layer through the opening.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

- 4. Any inquiry of a general nature or relating to the status of this application should be directed to the Group Receptionist whose telephone number is 571-272-2800. See MPEP 203.08.
- 5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to examiner Julio J. Maldonado whose telephone number is (571) 272-1864. The examiner can normally be reached on Monday through Friday.
- 6. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri, can be reached on (571) 272-1855. The fax number for this group is 703-872-9306 for before final submissions, 703-872-9306 for after final

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submissions and the customer service number for group 2800 is (703) 306-3329.

Updates can be found at http://www.uspto.gov/web/info/2800.htm.

Julio J. Maldonado Patent Examiner Art Unit 2823

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Julio J. Maldonado May 6, 2004

Primary Examiner